



Modeling and Input Optimization Under Uncertainty for a Collection of RF MEMS Devices.

SAND2006-6576C

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Albuquerque, NM

2006 ASME International Mechanical Engineering Congress and Exposition

Chicago, IL

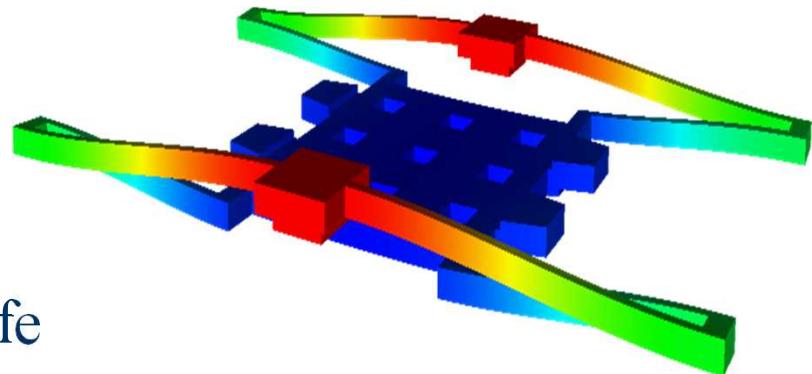
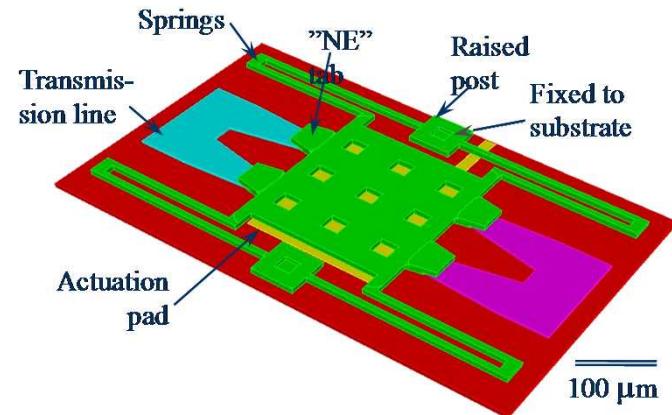
November 2006

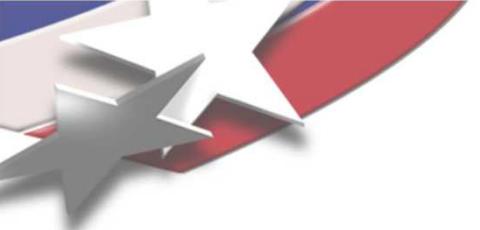
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Introduction

- ◆ There has been significant interest in RF MEMS switches because they can potentially provide:
 - very low power consumption
 - high isolation
 - excellent linearity
 - contained in a compact package
- ◆ One significant challenge is obtaining the high reliability required.
 - Previous studies have observed orders of magnitude increase in life when the impact velocity of the switches is reduced.



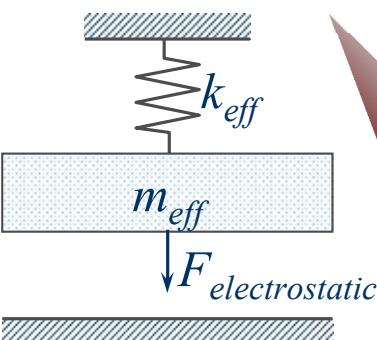
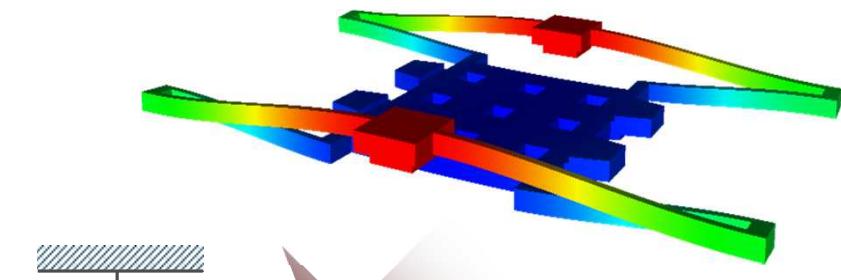
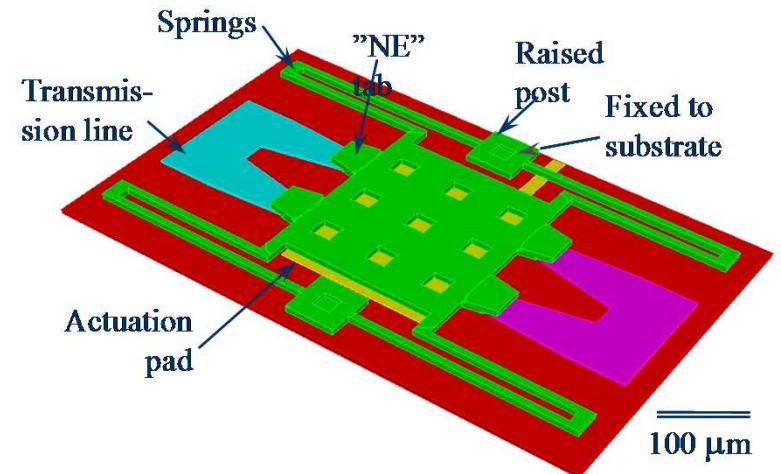


Outline

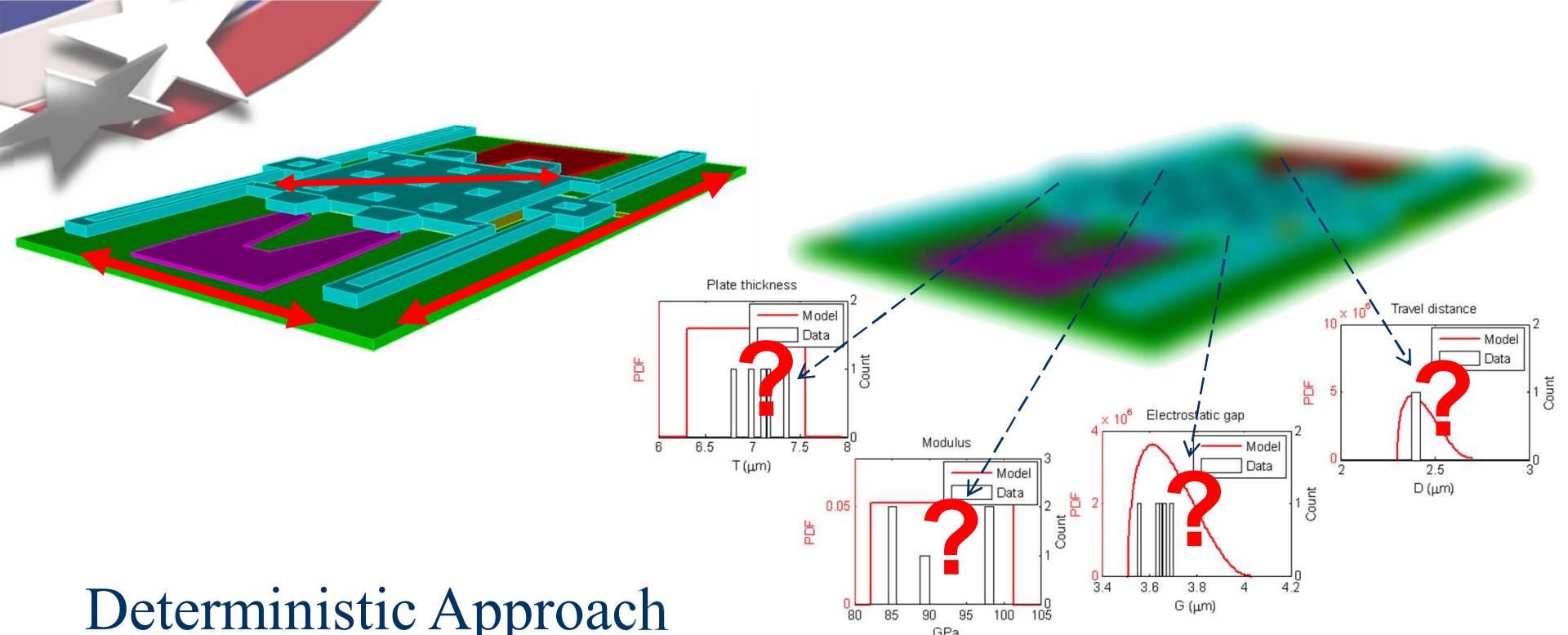
- ◆ Switch design and uncertainty model
- ◆ Unshaped waveform
- ◆ Deterministic optimization
- ◆ Optimization Under Uncertainty (OUU)
 - Waveform for current design OUU
 - Effect of a design change and OUU
 - Effect of process improvement and OUU
- ◆ Conclusions
- ◆ Wild cheering and applause

Switch Design

- ◆ RF Switch consists of a stiff plate suspended by four folded leaf springs.
- ◆ A voltage is applied to a pad under the plate resulting in an electrostatic force that closes the switch.
- ◆ The switch is well approximated by a single-degree of freedom model.
 - The input is shaped to limit excitation to higher modes to assure that this assumption is valid.



SDOF Model



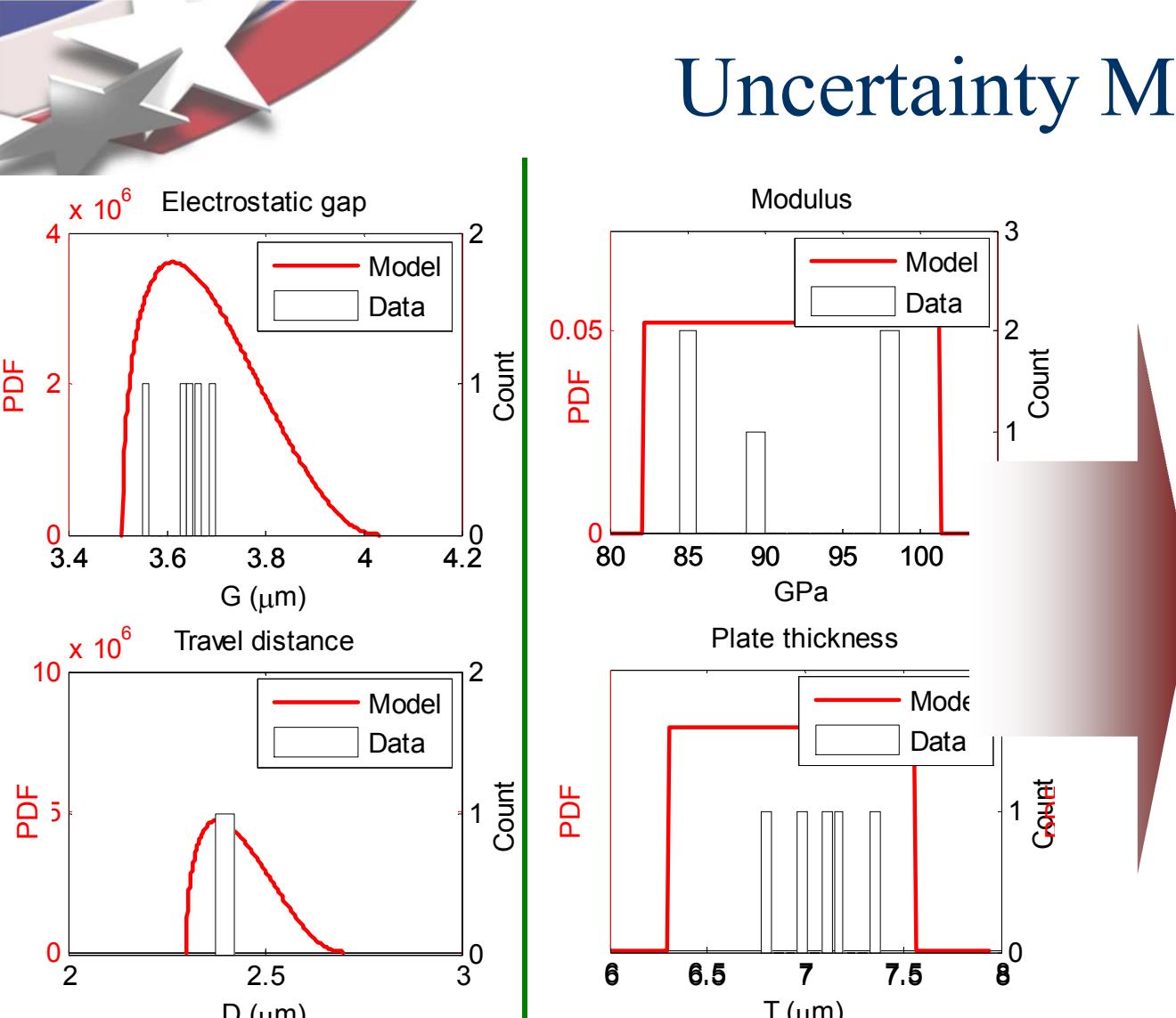
Deterministic Approach

- Variation in switch parameters is ignored.
- Waveform designed semi-analytically to satisfy the switch with average parameters.
- Succeeds only if:
 - The parameters of the switches don't vary too much or
 - If the optimum is insensitive to variation.

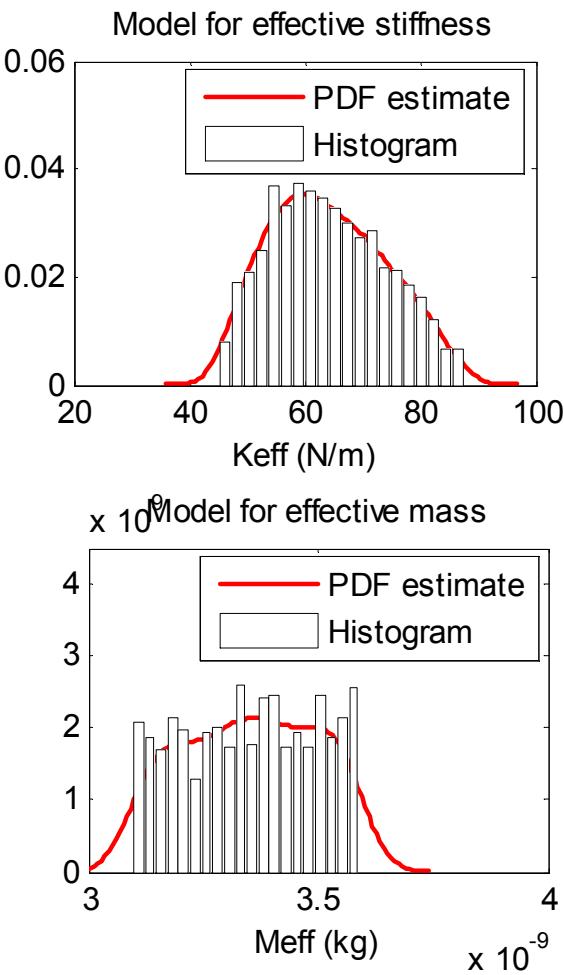
OUU Approach

- Random variation in switch parameters described by probability density functions (PDFs).
- Waveform optimized numerically to minimize impact velocity over the ensemble of switches.

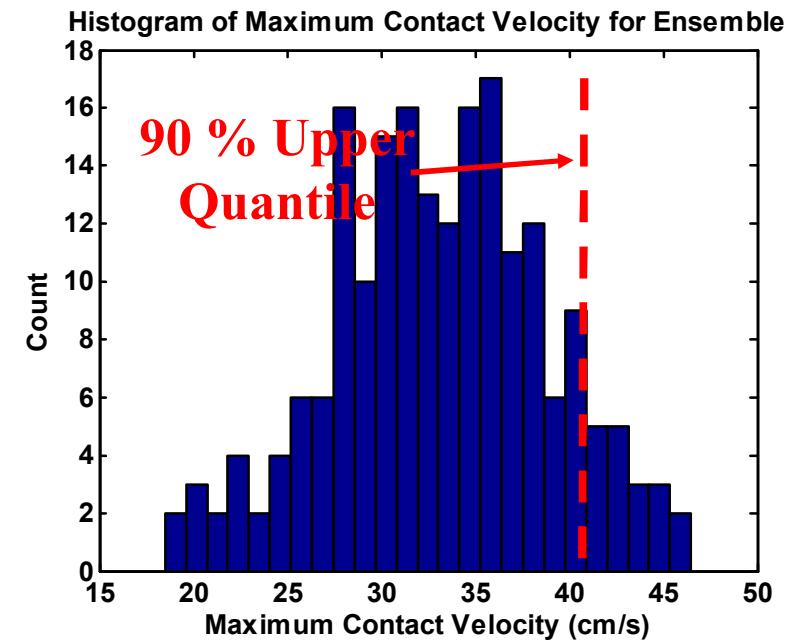
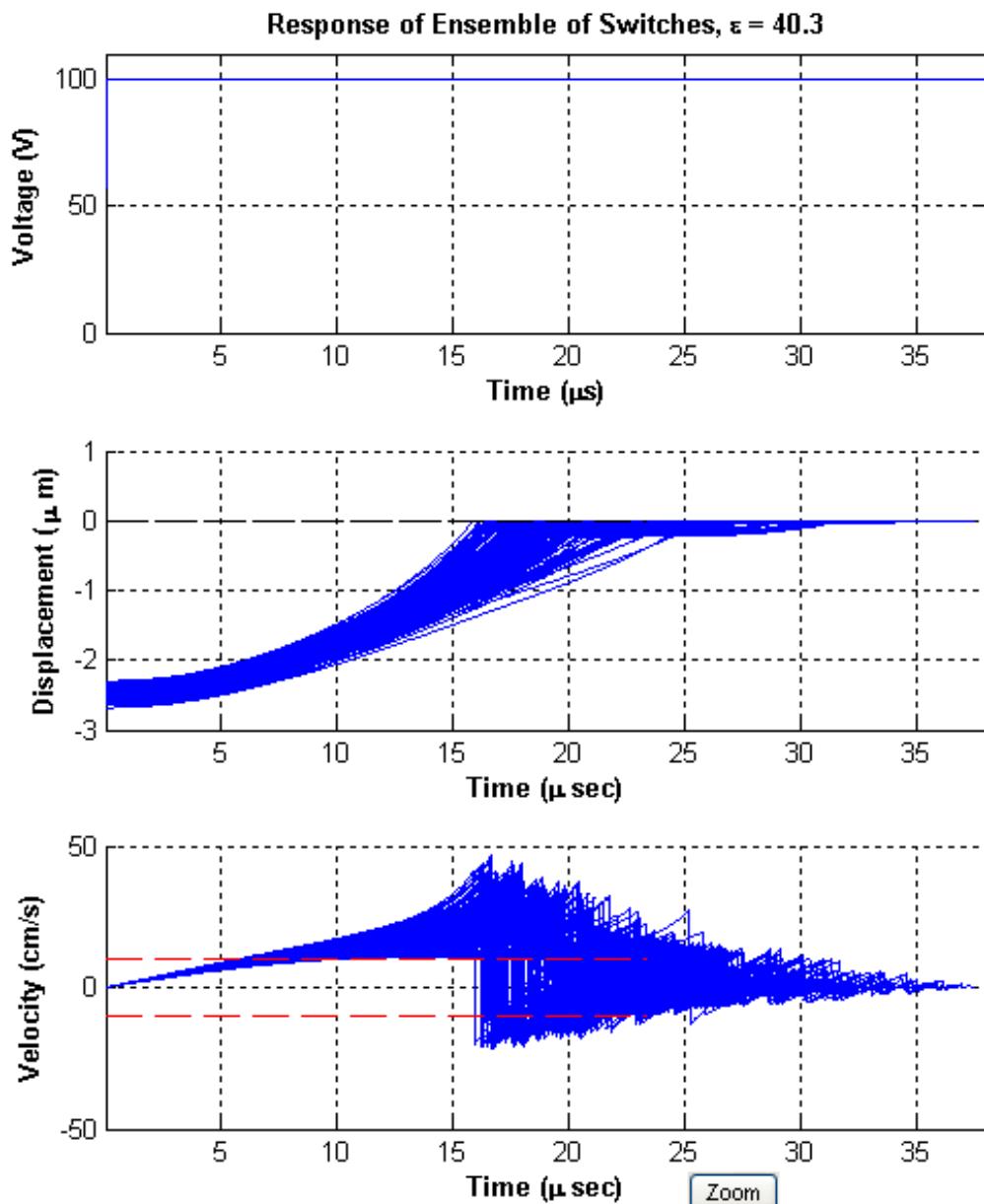
Uncertainty Model



- Plate thickness, electrostatic gap, travel distance and elastic modulus were measured and fit to uniform and Beta Probability Density Functions (PDFs).
 - Expert opinion was used to augment the data since few samples were available.
 - Modulus and Thickness were used to deduce effective mass and stiffness.

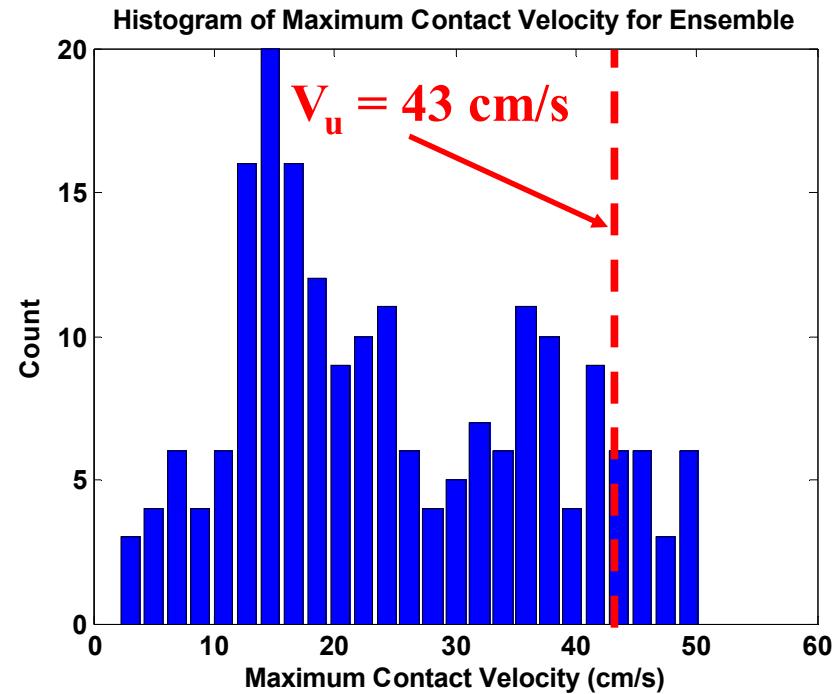
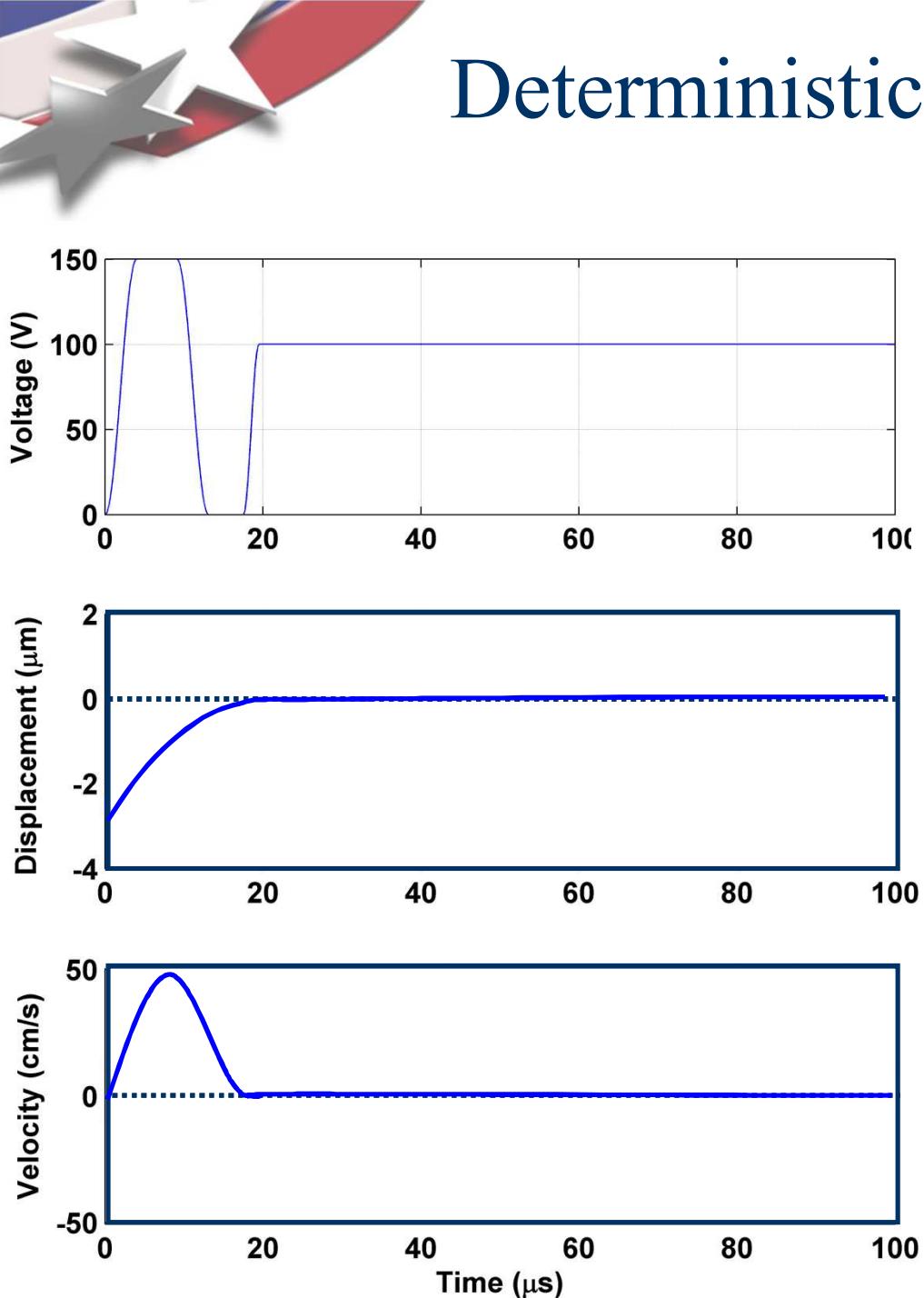


Response without Input Shaping



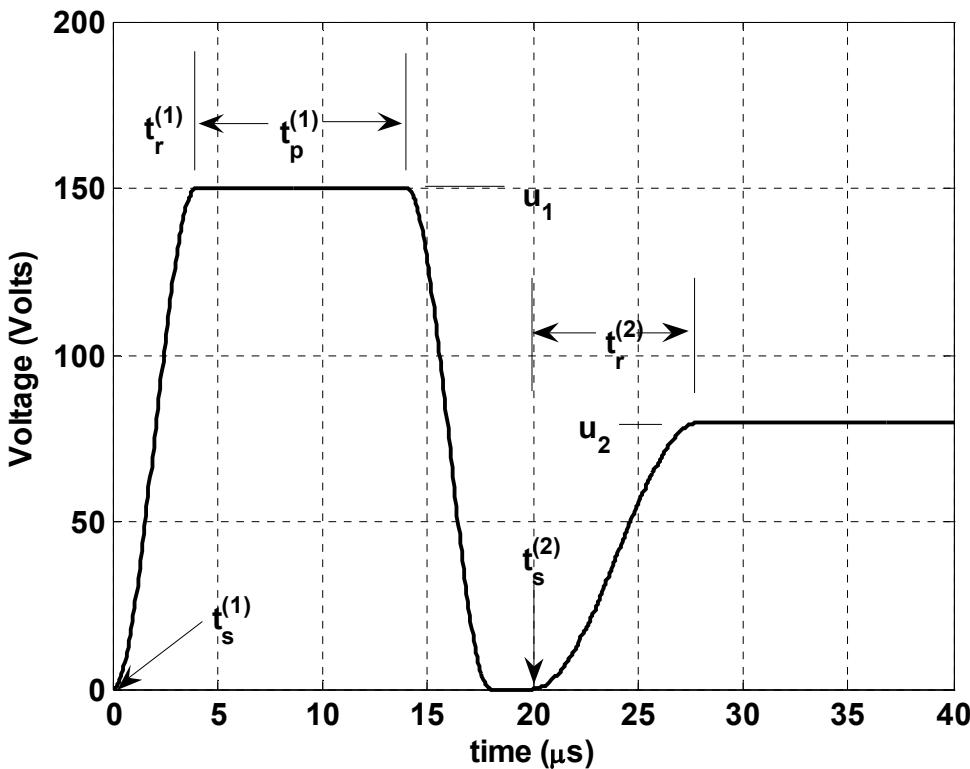
- ◆ 90% of the switches experience maximum contact velocities below 40.3 cm/s

Deterministic Waveform Design



- ◆ A waveform that is optimum in a deterministic sense gives higher contact velocities than an unshaped waveform when applied to the ensemble of switches.

Optimization Objective & Strategy



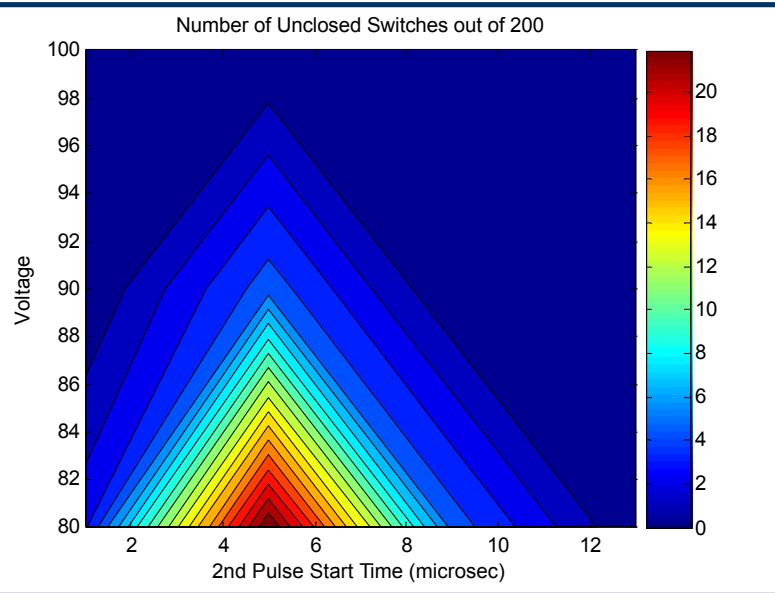
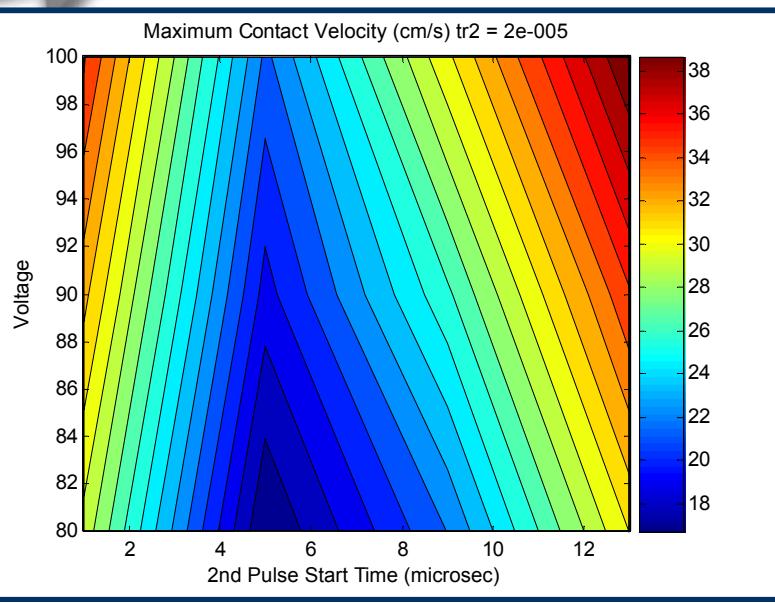
◆ Optimization Objective:

- $g(t_s^{(1)}, \dots) = v_u + c_{nc} * p_{nc}$
 - 90% of the switches experience contact velocities lower than v_u
 - ◆ (i.e. $P(V_{max} > v_u) = 0.10$)
 - p_{nc} is the probability that a switch doesn't close in 250 μs
 - c_{nc} is a constant to weight the relative importance of the two

◆ Optimization Strategy:

- Set $u_2 = 0$ and adjust $t_p^{(1)}$ (duration of first pulse) until the maximum contact velocity for the ensemble of 200 switches is ~ 10 cm/s.
- Use exhaustive search to find starting values for $t_s^{(2)}$ (start time of second pulse), $t_r^{(2)}$ (rise time of second pulse) and u_2 (maximum voltage of second pulse).
- Refine using Nelder-Mead Simplex algorithm.

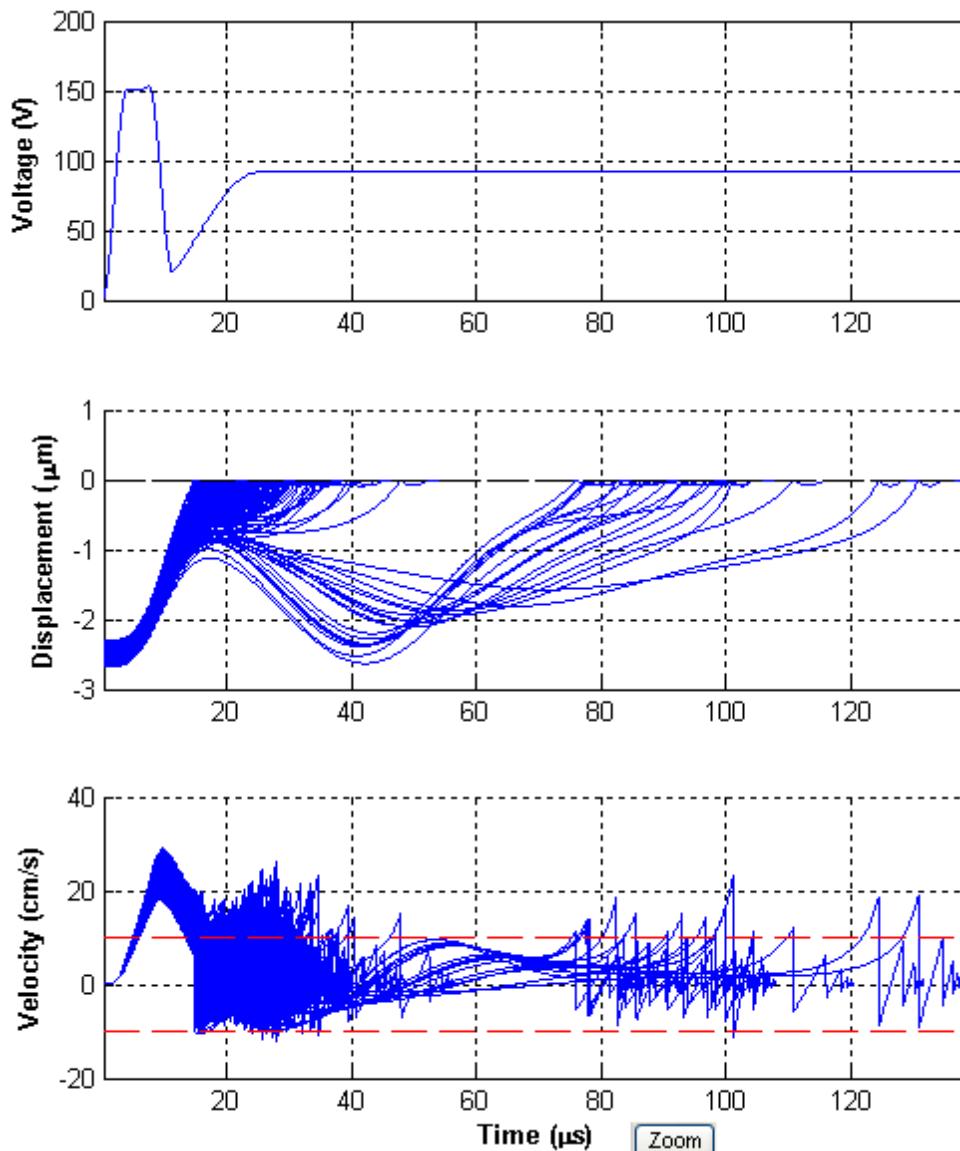
Optimization Strategy



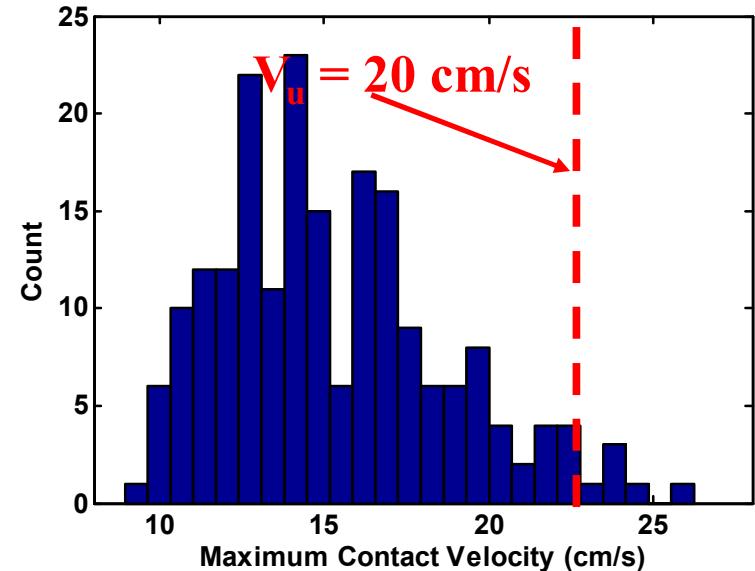
◆ Comments:

- Exhaustive search used to find starting values for Nelder-Mead.
- Nelder-Mead Simplex used to refine initial estimates, typically resulting in a 1 cm/s reduction in the maximum contact velocity from that found by exhaustive search.
- Also attempted using the DIRECT (global) optimization algorithm, yet many iterations were required to obtain reasonable results.

OUU Waveform Design



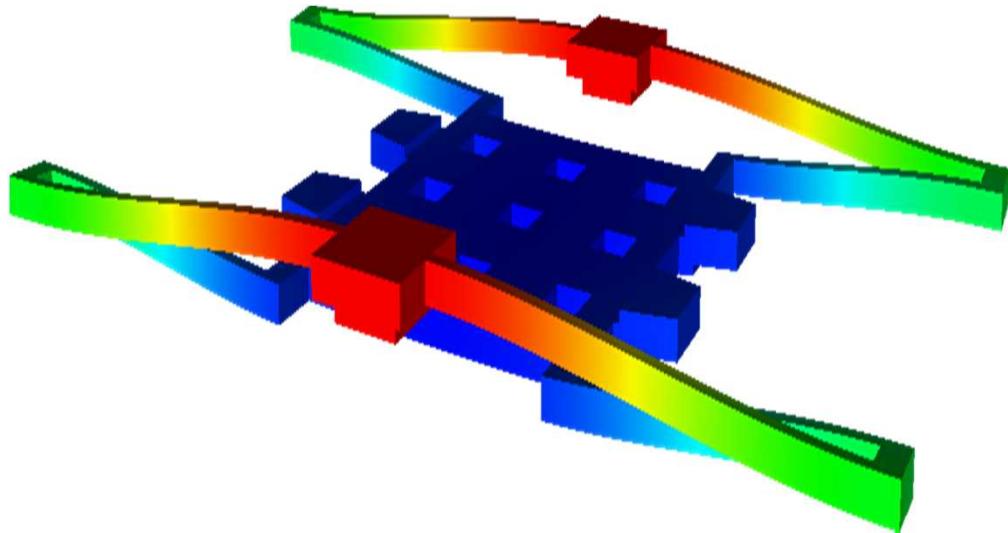
Histogram of Maximum Contact Velocity
for Ensemble, $\mu = 15.2653$



- ◆ Results:
 - 90% have maximum contact velocities below 19.7 cm/s
 - The mean maximum contact velocity is 15.3 cm/s
 - These represent improvements of more than 50% compared to the unshaped waveform or the deterministically designed waveform.
- ◆ None of the switches have a contact velocity near zero.

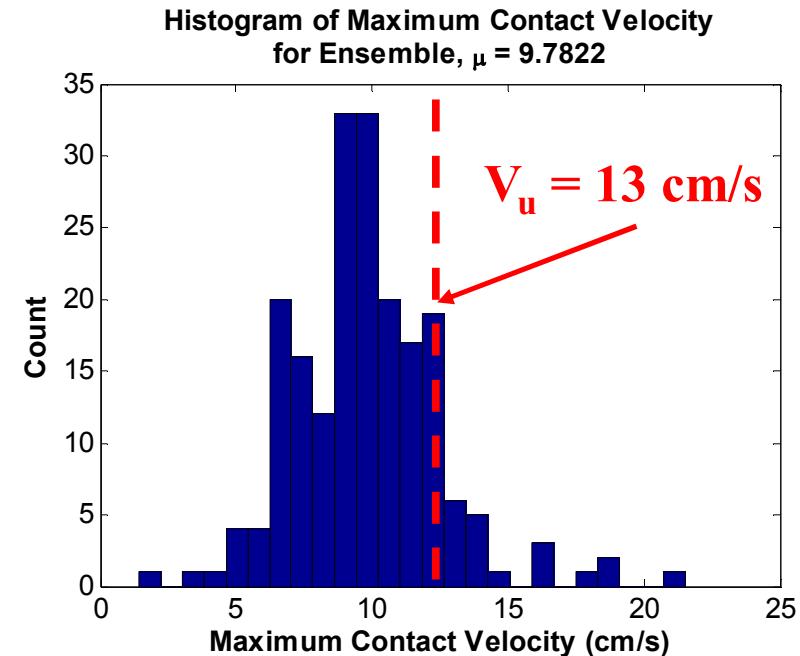
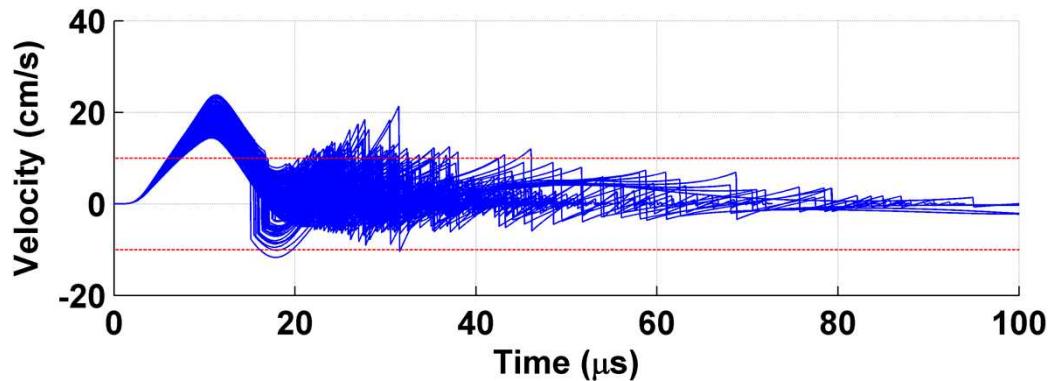
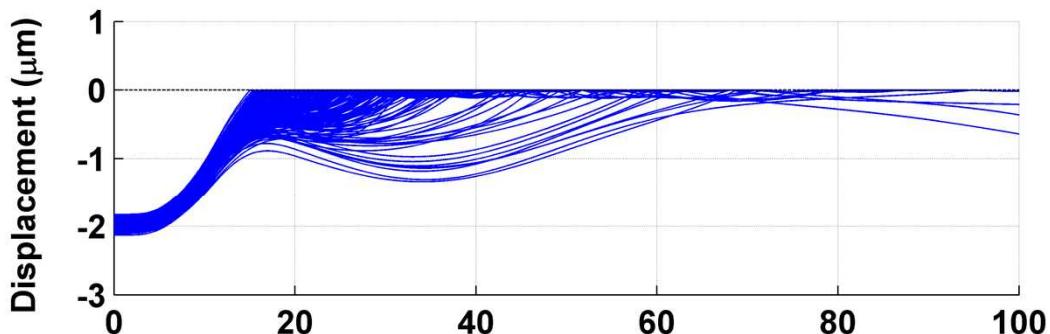
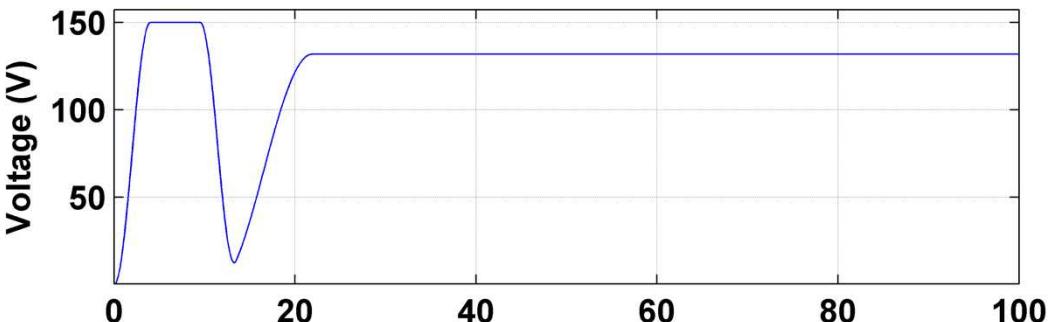
Design Change

- ◆ Electrostatic force varies with the inverse square of the electrostatic gap (G) minus the switch displacement (X).
- ◆ The displacement must be less than the travel distance (D).
- ◆ The system is unstable for:
 - $X > G/3$.
- ◆ Currently:
 - $0.59 \cdot D/G \cdot 0.75$
- ◆ The design was modified to reduce this ratio resulting in
 - $0.41 \cdot D/G \cdot 0.52$.
- ◆ This design does not venture as far into the unstable region as the previous did.



$$F_{electrostatic} = \frac{\alpha u^2}{(G-X)^2}$$
$$X \leq D$$

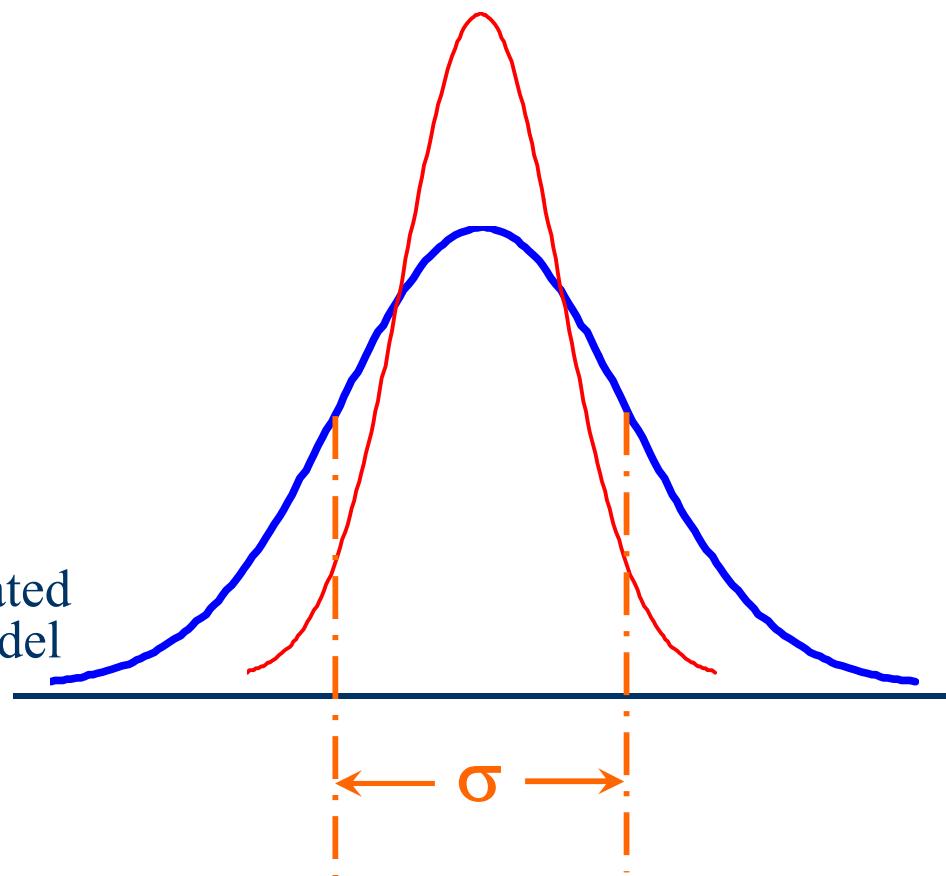
Design Change and OUU



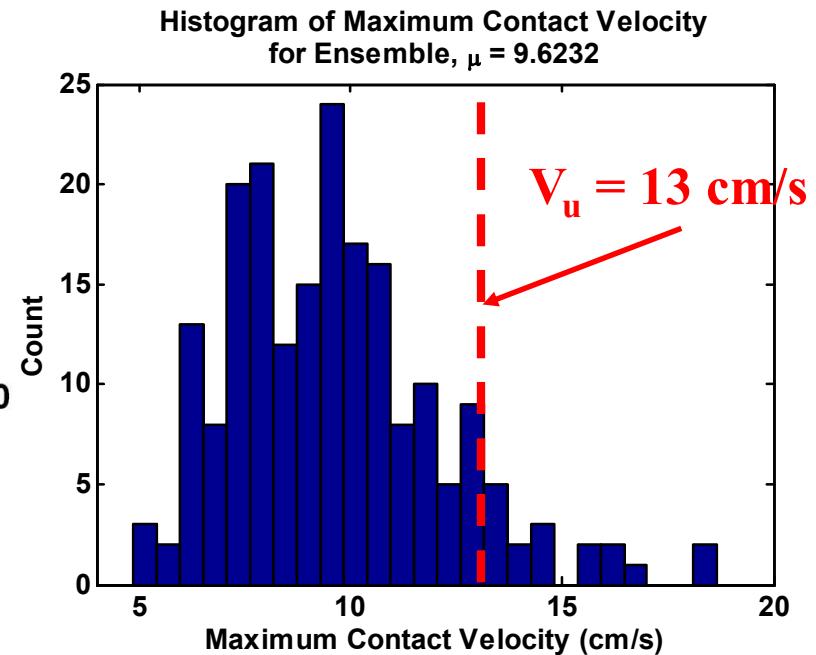
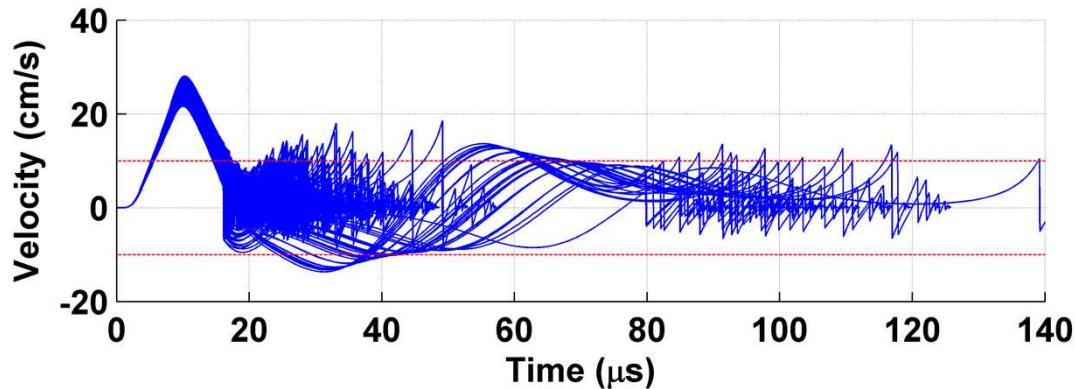
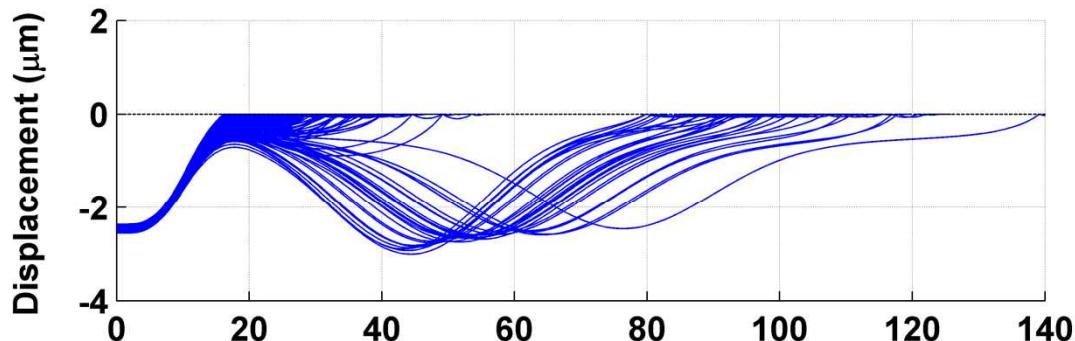
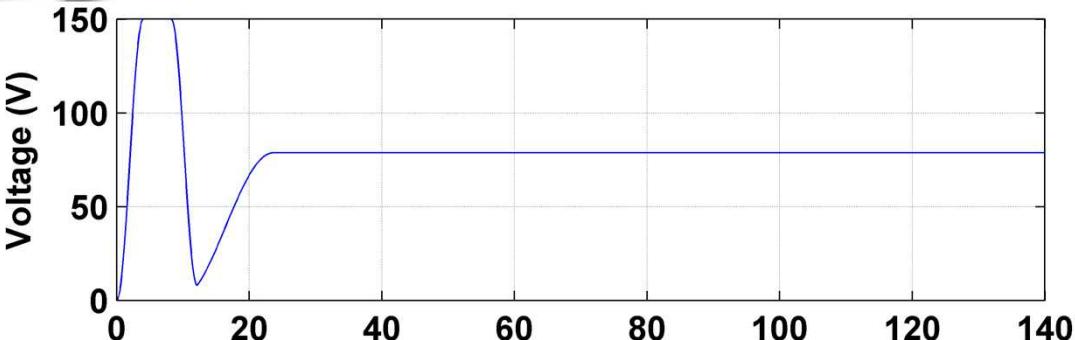
- ◆ 35 % reduction in upper and mean contact velocities.
 - Upper 12.5 cm/s from 19.7 cm/s
 - Mean 9.8 cm/s from 15.3 cm/s

Process Improvement

- ♦ How much would the performance improve if the process repeatability were improved by 50%?
 - Coefficient of Variation of:
 - Gap Distance
 - Travel Distance
 - Thickness
 - were decreased by 50%. ($COV = \text{standard deviation} / \text{mean}$).
 - Optimization procedure was repeated with this modified uncertainty model for the switch.
- ♦ This level of improvement may not be feasible, but this type of analysis can provide motivation for allocating resources to process improvement.

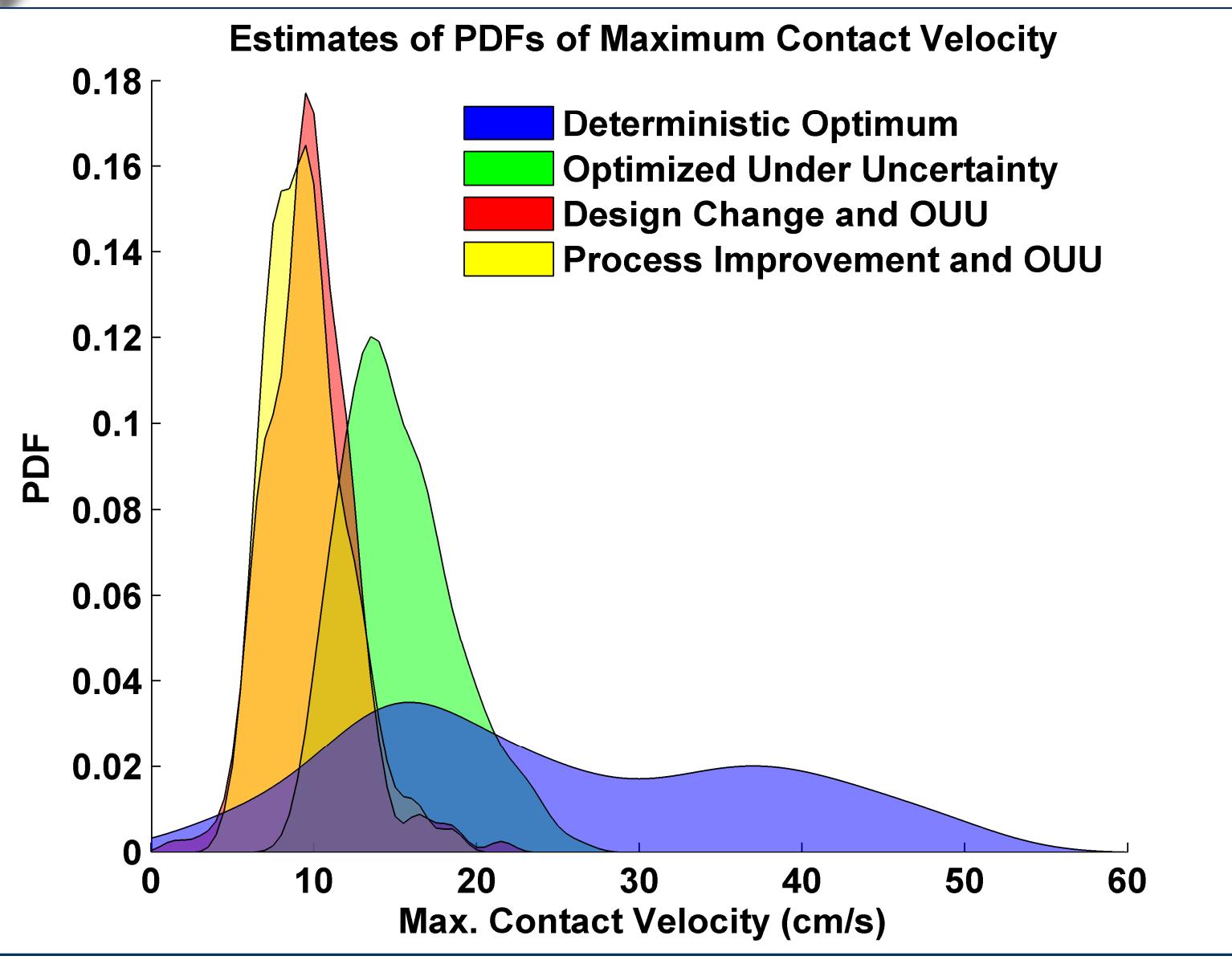


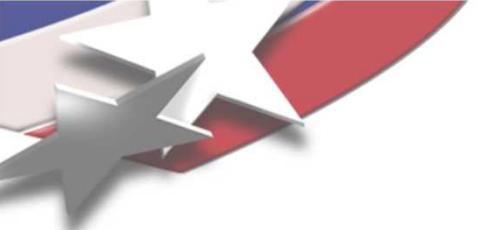
Process Improvement and OUU



- ◆ Simulated the effect of process improvement:
 - Reduced the COV of gap, travel and thickness by 50%
- ◆ >35% reduction in upper and mean contact velocities
 - Upper 12.8 cm/s vs 19.7 cm/s
 - Mean 9.6 cm/s vs. 15.3 cm/s

Summary





Conclusions

- ◆ Shaped waveforms can reduce the impact velocity that an ensemble of switches experiences.
- ◆ The contact velocity was reduced by 50% using the waveform that was optimized under uncertainty.
- ◆ Further reductions of 35% were demonstrated after modifying the switch design or reducing process variability. (Net reduction of 70%)
- ◆ Uncertainty must be accounted for when designing shaped waveforms.
 - A waveform that was optimum for the average switch actually increased the impact velocity when applied to the ensemble of switches.